

DOCUMENT 3/7
DOCUMENT NUMBER
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PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2001-234356
(43)Date of publication of application : 31.08.2001

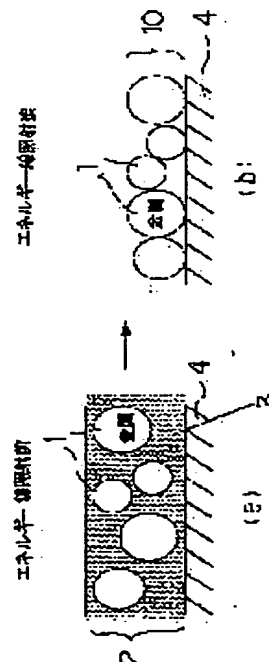
(51)Int.Cl. C23C 26/00
B05D 7/24
H01B 5/14
H01B 13/00

(21)Application number : 2000-047764 (71)Applicant : SEIKO EPSON CORP
(22)Date of filing : 24.02.2000 (72)Inventor : MORII KATSUYUK

(54) PRODUCING METHOD OF FILM AND FILM OBTAINED THEREBY

(57)Abstract:
PROBLEM TO BE SOLVED: To provide a method for inexpensively producing an electrically conductive film excellent in electric conductivity.

SOLUTION: In this producing method for a film, a colloidal layer is formed on a base material, and the surface of the colloidal layer is irradiated with an energy ray which imparts higher absorption strength to the colloidal layer than to the base material. In particular, the above colloidal layer is composed of a metallic colloidal layer, and as the above film, an electrically conductive film is suitably obtained. Moreover, the film in this invention can be obtained by the above producing method.



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